

Variability Panel

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Who is responsible for Library Quality

- This is fundamentally a business/contractual question
- ASIC
 - Owns flow and libraries responsible to make a working chip
 - Guard-band versus reliability / yield made by the Asic Vendor
- Fabless but Customer Owned Tooling
 - Customer makes the library and the flow and owns the quality
 - Customer owns the guard-band versus reliability / yield in partnership with fab
 - Fab agrees to make geometries within a certain error
 - Ownership of the spice model of the transistor quality is usually the foundry
 - Pre variation this was clean
 - Now the fab must control variation in some workable way
 - Simplex, TSMC, ATI partnership circa 2001 on lithography effects
- Own Fab
 - Internal problem but similar to COT between Fab and Library teams
 - Easier to get custom recipes in the process

Delay versus constraint variability

- It is easy to add guard-banding at every level
- This is very dangerous because when timing won't close and the inevitable desire to reduce the guard-band comes, we need to know where the guard-band is
- Delay calculation should match spice as closely as possible with absolutely minimal guard-band
 - This is the place to do everything possible to model variation and every effect possible
 - Keep the effects separable when possible for traceability in order to be sure to avoid double guard-banding the same thing.
- Constraint calculation is the place to add guard-band, one place

Proprietary Delay Models

- Standards are great when the state of the art has stabilized enough such that a 'standard' solution is acceptable
- For technology in flux, proprietary models lead the way and become future standards
- If the current standard models are not enough to do what needs to be done then we have to use proprietary models
- 'Not enough' can be spun by marketing, be real

Proprietary Delay Models

- Do we need tighter integration between Spice and library characterization?
 - If its needed for the next bullet, not clear
- Will we be able to do statistical characterization with reasonable accuracy and runtime?
 - So far we have not solved this problem in a workable way due to the resulting data size and use of that data, not the characterization runtime
- Do we need more waveform parameters for constraint characterization?
 - Yes, especially for highly resistive and noisy nets